

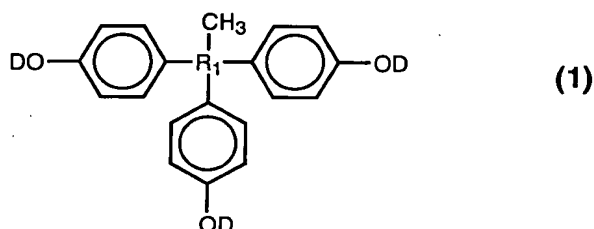
IN THE CLAIMS

Please amend the claims as follows:

Claim 1 (Currently Amended): A positive photosensitive resin composition characterized by comprising (A), (B) and (C);

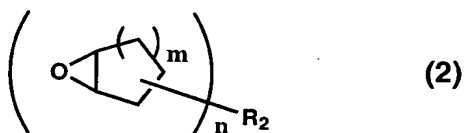
wherein (A) comprises an alkali-soluble resin which is comprising a copolymer essentially comprising an unsaturated carboxylic acid derivative and an N-substituted maleimide, and which has a number average molecular weight of from 2,000 to 20,000,

wherein (B) comprises a 1,2-quinone diazide compound of formula (1):



(wherein wherein each D independently is a hydrogen atom or an organic group having comprising a 1,2-quinone diazide group, wherein R1 is a tetravalent organic group, provided that at least one of D is an organic group having comprising a 1,2-quinone diazide group) group, and

wherein (C) comprises a crosslinking compound represented by formula (2), which is present in and from 5 to 50 parts by weight, per 100 parts by weight of the alkali-soluble resin, of a crosslinking compound represented by the formula (2):

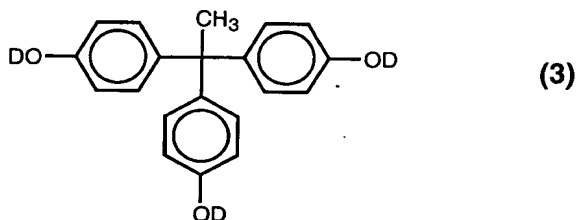


(wherein wherein n is an integer of from 2 to 10, m is an integer of from 0 to 4, and R2 is an n-valent organic group) group.

Claim 2 (Currently Amended): The positive photosensitive resin composition according to ~~of~~ Claim 1, wherein the alkali-soluble resin comprises a residual monomer ratio ~~in the alkali-soluble resin is of~~ at most 2.5 wt%.

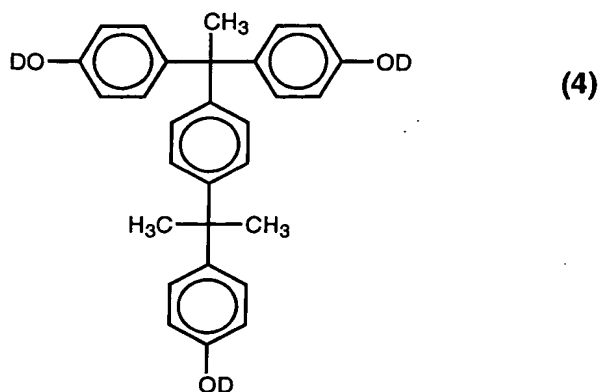
Claim 3 (Currently Amended): The positive photosensitive resin composition according to ~~Claim 1 or 2 of Claim 1, wherein~~ comprising the 1,2-quinone diazide compound is ~~contained~~ in an amount of from 5 to 100 parts by weight, per 100 parts by weight of the alkali-soluble resin.

Claim 4 (Currently Amended): The positive photosensitive resin composition according to ~~Claim 1, 2 or 3 of Claim 1, wherein~~ the 1,2-quinone diazide compound is a compound ~~represented by the following~~ of formula (3):



~~(wherein~~ wherein each D independently is a hydrogen atom or an organic group ~~having comprising a 1,2-quinone diazide group, provided that at least one of D is an organic group having comprising a 1,2-quinone diazide group) group.~~

Claim 5 (Currently Amended): The positive photosensitive resin composition according to ~~Claim 1, 2 or 3 of Claim 1, wherein~~ the 1,2-quinone diazide compound is a compound ~~represented by the following~~ of formula (4):



~~(wherein~~ wherein each D independently is a hydrogen atom or an organic group having comprising a 1,2-quinone diazide group, provided that at least one of D is an organic group having comprising a 1,2-quinone diazide group group).

Claim 6 (Currently Amended): The positive photosensitive resin composition according to any one of Claims 1 to 5 of Claim 1, wherein the alkali-soluble resin does not comprise an ~~has no~~ epoxy group.

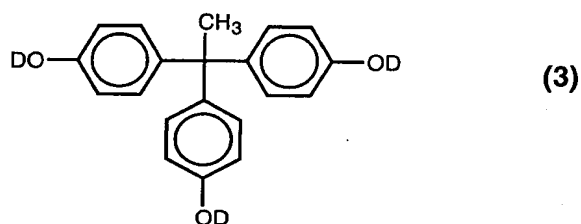
Claim 7 (Currently Amended): The positive photosensitive resin composition according to any one of claims 1 to 6 of Claim 1, wherein n is an integer of from 3 to 10, and m is an integer of 2, in the crosslinking compound ~~represented by the~~ of formula (2).

Claim 8 (Currently Amended): The positive photosensitive resin composition according to any one of Claims 1 to 7 of Claim 1, ~~which contains~~ further comprising a surfactant in an amount of from 0.01 to 5 parts by weight per 100 parts by weight of the alkali-soluble resin.

Claim 9 (Currently Amended): The positive photosensitive resin composition ~~according to any one of Claims 1 to 8 of Claim 1~~, wherein the positive photosensitive resin composition is a solution ~~having~~ comprising a solid content concentration of from 1 to 50 wt%.

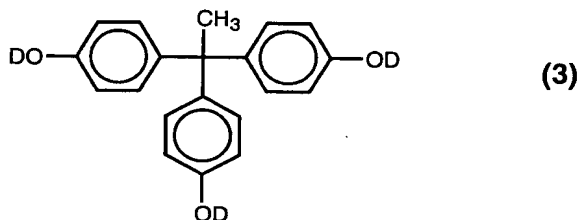
Claim 10 (New): The positive photosensitive resin composition of Claim 2, comprising the 1,2-quinone diazide compound in an amount of from 5 to 100 parts by weight, per 100 parts by weight of the alkali-soluble resin.

Claim 11 (New): The positive photosensitive resin composition of Claim 2, wherein the 1,2-quinone diazide compound is a compound of formula (3):



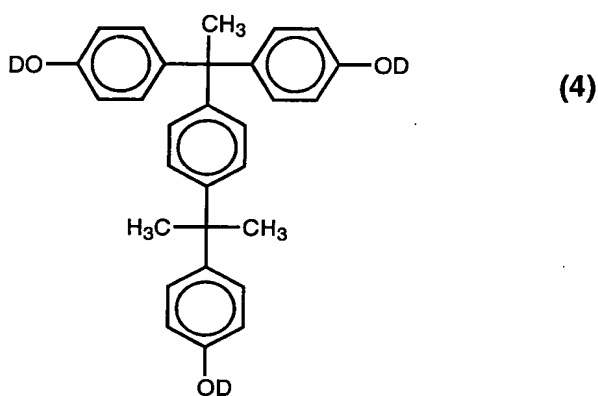
wherein each D independently is a hydrogen atom or an organic group comprising a 1,2-quinone diazide group, provided that at least one of D is an organic group comprising a 1,2-quinone diazide group.

Claim 12 (New): The positive photosensitive resin composition of Claim 3, wherein the 1,2-quinone diazide compound is a compound of formula (3):



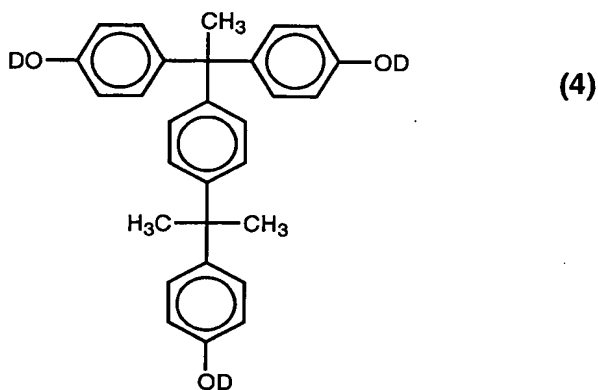
wherein each D independently is a hydrogen atom or an organic group comprising a 1,2-quinone diazide group, provided that at least one of D is an organic group comprising a 1,2-quinone diazide group.

Claim 13 (New): The positive photosensitive resin composition of Claim 2, wherein the 1,2-quinone diazide compound is a compound of formula (4):



wherein each D independently is a hydrogen atom or an organic group comprising a 1,2-quinone diazide group, provided that at least one of D is an organic group comprising a 1,2-quinone diazide group.

Claim 14 (New): The positive photosensitive resin composition of Claim 3, wherein the 1,2-quinone diazide compound is a compound of formula (4):



wherein each D independently is a hydrogen atom or an organic group comprising a 1,2-quinone diazide group, provided that at least one of D is an organic group comprising a 1,2-quinone diazide group.

Claim 15 (New): The positive photosensitive resin composition of Claim 2, wherein n is an integer of from 3 to 10, and m is an integer of 2, in the crosslinking compound of formula (2).

Claim 16 (New): The positive photosensitive resin composition of Claim 3, wherein n is an integer of from 3 to 10, and m is an integer of 2, in the crosslinking compound of formula (2).

Claim 17 (New): The positive photosensitive resin composition of Claim 4, wherein n is an integer of from 3 to 10, and m is an integer of 2, in the crosslinking compound of formula (2).

Claim 18 (New): The positive photosensitive resin composition of Claim 5, wherein n is an integer of from 3 to 10, and m is an integer of 2, in the crosslinking compound of formula (2).

Claim 19 (New): The positive photosensitive resin composition of Claim 2, further comprising a surfactant in an amount of from 0.01 to 5 parts by weight per 100 parts by weight of the alkali-soluble resin.

Claim 20 (New): The positive photosensitive resin composition of Claim 3, further comprising a surfactant in an amount of from 0.01 to 5 parts by weight per 100 parts by weight of the alkali-soluble resin.